

Cambridge University Press & Assessment

978-1-605-11298-5 — Amorphous and Polycrystalline Thin-Film Silicon Science and Technology —2011

Edited by Baojie Yan, Qi Wang, Helena Gleskova, Chuang Chuang Tsai, Seiichiro Higashi

Copyright information

[More Information](#)

CAMBRIDGE UNIVERSITY PRESS

University Printing House, Cambridge CB2 8BS, United Kingdom

One Liberty Plaza, 20th Floor, New York, NY 10006, USA

477 Williamstown Road, Port Melbourne, VIC 3207, Australia

314-321, 3rd Floor, Plot 3, Splendor Forum, Jasola District Centre, New Delhi - 110025, India

103 Penang Road, #05-06/07, Visioncrest Commercial, Singapore 238467

Cambridge University Press is part of the University of Cambridge.

It furthers the University's mission by disseminating knowledge in the pursuit of education, learning and research at the highest international levels of excellence.

www.cambridge.org

Information on this title: www.cambridge.org/9781605112985

Materials Research Society

506 Keystone Drive, Warrendale, PA 15086, USA

<http://www.mrs.org>

© Materials Research Society 2012

This publication is in copyright. Subject to statutory exception and to the provisions of relevant collective licensing agreements, no reproduction of any part may take place without the written permission of Cambridge University Press.

This book has been registered with Copyright Clearance Center, Inc.

For further information please contact the Copyright Clearance Center, Salem, Massachusetts.

First published 2012

CODEN: MRSPDH

A catalogue record for this publication is available from the British Library

ISBN 978-1-605-11298-5 Hardback

Cambridge University Press has no responsibility for the persistence or accuracy of URLs for external or third-party internet websites referred to in this publication, and does not guarantee that any content on such websites is, or will remain, accurate or appropriate.